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Surface Effect in Metal Oxide-Based Nanodevices

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As the devices shrink to nanoscale, surface-to-volume ratio increases and the surface-environment interaction becomes the main factor to affect the device performance. The variation of electronic properties regarding the surface band bending, gas chemisorption or photodesorption, native surface defects, and surface roughness, are called “surface effects”. Such effects are ambiguous since they can be either a negative or beneficial effects, depending on the environmental conditions and device applications. This review provides an introduction of the surface effects on different types of nanodevices, offering the solutions to respond to their benefits and negative effect, and provides outlooks on further applications regarding the surface effect. This review is beneficial for designing nano-enabled photodetectors, harsh electronics, memories, sensors and transistors via surface engineering.

1. Introduction

Since the beginning of the 21st century, the scientific community has demonstrated many promising applications based on metal oxides due to their unique physical, chemical and optical properties. The distinct properties of metal oxides originate from the surface effects, including surface band bending (SBB), surface roughness, gas chemisorption, photodesorption, and surface-related defects/states. Because metal oxide can be synthesized by a great variety of available depositing methods, complex-shaped nanostructures are achievable. As shrinking the sizes, the increase in surface area to volume ratio (S/V) make the surface effect become more pronounced. From electrical point of view, because the charge screening length (Debye length) is in the same level (~100 nm) of material thickness, altering the surface states could cause a dramatic change in electric properties. At the nanoscale level, the surface effect is ambiguous since it can act as either a detrimental or beneficial role depending on the application. Regarding the vulnerability of nanomaterials to the variance of surroundings, such effects are usually detrimental in device level applications. For example, a problem faced in an oxide transistor is that the interaction with ambient molecules and illumination photons could cause degradation of devices’ performance. In addition, the performance of resistive switching–based devices could degrade with variation of environment conditions due to the environment-induced instability. On the other hand, facilitated by surface effects, the performance and sensitivities of the nano-enabled sensors could be greatly improved. For example, nanostructures with higher S/V ratio exhibit superior sensitivity in optical and chemical sensors comparing to their thin film counterparts. Furthermore, surface modifications enable the electronic properties to be engineered in nanoscale. Effective modifications could be achieved by chemical or physical approaches, helping to improve the sensitivity, detection selectivity, and stability of the devices. Surface modification are not only important in metal oxide-based but every class of nanoscale devices, such as organic thin-film transistors (OTFTs). By applying the surface effect in nanoscale devices, versatile applications can be realized which pave new ways for development of high-potential technology beyond the well-established silicon-based electronics as well as optoelectronics.

In order to develop the novel application of nanostructure utilizing the surface effect, it is very important to understand how the physical properties are affected as the material’s dimensions are reduced. In this review, we present the surface effect on metal oxide-based nanodevices, including photodetectors, harsh electronics, resistive random access memories, gas sensors and transistors. We highlight the benefits, discuss the major constraints arising from its detrimental consequences, and provide perspective outlooks for future device applications.

2. Surface Effect in Different Types of Nanodevices

2.1. Applying the surface effect in nano-optoelectronics and eliminating the surface-induced instability for harsh electronics

Metal-oxide nanomaterials are promising in applications of photodetection and photovoltaic for their ultrahigh sensitivity and spectral selectivity. As a record, ultrahigh internal photocurrent up to $10^5$ has been observed in ZnO nanowire (NW) device. High photosensitivities are attributed to the presence of abundant deep-level states at metal oxides’ surface...
combining with a gas desorption/reabsorption process. In detail, the trap states at surfaces serve as the adsorption sites for gas molecules, namely O₂, to adsorb on the metal oxide surface and capture free electrons. The absorbed molecules act as acceptors which reduce the free carrier density and deplete the surface electron states, leading to the formation of the space charge region and surfaces band bending (SBB). While illuminating by the light, the photo-generated electron-hole pairs are separated by the built-in potential formed by SBB, where the holes neutralize the O²⁻ which leads to a desorption process of the oxygen. Therefore, since the holes are “trapped” by the oxygen desorption/reabsorption process, the lifetime of the electrons is greatly prolonged, leading to the ultrahigh photogain.

Taking ZnO NWs as an example, the bend binding is up to 1.5 eV and a few tens of nanometers in width (1.5 eV and 43 nm measured in Air, respectively), determined by ultraviolet photoelectron spectroscopy (UPS) (Figure 1a). A 100 °C heat treatment could cause a decrease of the SBB (from 1.5 eV to 0.74 eV and 43 nm to 30 nm) attributed to the removal of adsorbed oxygen molecules from the nanomaterials’ surfaces. On the other hand, decoration of Au nanoparticles (NPs) can enhance the SBB to 2.3 eV and 53 nm in width due to the creation of open-circuit nano-Schottky junctions and catalytically increase the amount of the O₂ adsorbs (Figure 1b). Since the photon-electron conversion behaviours are dominated by the SBB, optoelectronics properties of metal oxide are tuneable through the engineering of this trivially thin region near the surface.\(^\text{11,12}\) One simple way to control the optoelectronic properties is by engineering the size of the nanomaterials. For example, ZnO NW devices can be fully depleted or partially depleted, simply determining by the diameter of the NWs.\(^\text{11}\) Decreasing the diameter of NWs from 400 to 100 nm, the response speed increases from 31 to 5 s due to the diameter-dependent SBB. To engineer the surface effect, Chen et al. have shown that by decorating the Au NPs, the sensitivities of ZnO NWs-based photodetectors can be enhanced due to the enhancement of the surface effect.\(^\text{12,13}\) To further deplete the surfaces, Retamal et al. recently have demonstrated that n-type ZnO NWs decorated by p-type single-crystalline NiO NP decoration can produce a photogain of \(\sim 2.8 \times 10^3\), which are 3 orders of magnitude higher than that of pristine ZnO NWs (Figure 1c).\(^\text{18}\)

However, as a side effect, high photogain metal-oxide devices normally suffer from the detrimental responsivity-speed trade-off owing to the slow adsorption/desorption process.\(^\text{16}\) This effect reduces the response speed to an unsatisfied value from several to several hundred seconds. Those faulty features limit their applications for various tasks and preclude the opportunities of metal-oxide nanodevices for real-time sensing. Some strategies have been proposed for the improvement of the response speed. From the electrical viewpoint, during light illumination, the generated electrons keep on accumulation, resulting in a rise of photocurrent until the equilibrium of O₂ desorption and readsorption processes. As turning off light, holes recombine quickly with electrons, while there are still a lot of electrons left in the metal oxides. It takes time for oxygen molecules to reabsorb onto the surface and capture these electrons, leading to a slow recovery time. By fabricating the device with Schottky contact, photon-electron couplings within materials can be facilitated and the response speed can be improved via the quick regulation of the Schottky barrier height.\(^\text{19,20}\) The use of one-Schottky-contact geometry reported by Zhou et al. demonstrates that both the sensitivity of a ZnO NW photodetector can be greatly promoted with an improved response time of 0.6 s.\(^\text{16}\) Multiple junctions can be formed by introducing a network scheme, which is an effective approach to improve recovery speed. For example, Chen et al. have shown that by fabricating the devices in a network manner, the response speed can be improved by 2 order compared to the single nanobelt devices (Figure 2a and 2b).\(^\text{21,22}\) To maximize the Schottky contact, modification through a nanostructure design, for example, core-shell geometries or decoration of metal particles provides viable routes for the same purpose.\(^\text{23}\) For example, Hsu et al. reported an integration of multi-walled carbon nanotubes (MWCNT) and TiO₂ shells to form radial Schottky barriers in a core-shell fashion (Figure 2c).\(^\text{23}\) By this core-shell design, radial Schottky barriers between carbon nanotube cores and TiO₂ shells can effectively regulate electron transport, leading to ultrahigh photogain (\(1.4\times10^3\)) and the ultrashort response/recovery times (4.3/10.2 ms) (Figure 2b). Additionally, radial Schottky junction and defect band absorption broaden the detection range (UV–visible) (Figure 2d).
In the view of optics, performance of nano-optoelectronics can be enhanced by employing nanophotonic technique which supports a sophisticated management of light. For example, the technique of photon management using nanostructures has been widely used to boost the efficiency of photodetectors, light emitting diode, and solar cells.\textsuperscript{7,24-28} Considering the surface effect of metal oxide materials, light absorption near the surface is much more efficient than the absorption in deeper region of the bulk. As such, a resonant mode capable of near-surface light concentration is preferred, which can prevent intrinsic optical losses. Recently, we demonstrate a resonant scheme that can facilitate the light-matter coupling by exciting resonance within multi-nanosheled ZnO structures.\textsuperscript{29} Due to the resonance-assisted effect by the concentric shells, the nanoshells can absorb $>90\%$ of UV light as compared with an equivalent volume of bulk counterparts. The nanoshell devices show enhanced optoelectronic performance and omnidirectional detectability both for incident angle and light polarizations. The general design principles behind the multishelled hollow ZnO nanoshells pave a new way to improve the performance of sophisticated nanophotonic photodetectors.

By introducing high-crystallinity metal oxide materials, one can eliminate the surface effect as to improve the stabilities of photodetectors for uses in extreme conditions. For example, Wei et al. demonstrate a fully-transparent photodetectors based on $\beta$-Ga$_2$O$_3$, which is capable of being operated under high temperature (700 K) and high voltage (200 V) conditions without breaking down.\textsuperscript{30} He shows that under different oxygen concentration (i.e., vacuum ($10^{-7}$ Torr), air, and pure oxygen), the performance of metal oxide photodetectors does not change significantly, indicating that the photocurrent is not dominated by surface effect due to the superior crystal quality. This work demonstrates an effective way to fabricate photodetectors for uses in extreme operation conditions.

Another field related to surface effect is the harsh environment which is an emerging field aiming to promote device capability in strict environment conditions. Specific applications including oil, gas, geothermal, aircraft/automotive engine, aerospace/military, and industrial uses, require this type of devices for operating in extremes of radiation, pressure, temperature, shock, and chemically corrosive liquids/gases environments. To develop optoelectronics for harsh environments, we recently show that the photodetectors made by AlN can work at temperature up to 300 °C with radiation tolerance up to $10^{13}$ cm$^2$ of 2-MeV proton fluences because of its superior thermal stability and high radiation resistance.\textsuperscript{31} To further improve the performance in harsh environments, by introducing the multiple quantum wells (MQWs) into solar cells the efficiency can be enhanced by 0.52%/°C and exhibit superior radiation robustness (lifetime 430 years under solar storm proton irradiation) for their strong atomic bonding direct-bandgap characteristics. This study also provides valuable routes for future developments in self-powered har electronics.

2.2. Surface effect in metal-oxide memory devices and their passivation

Resistive random access memory (ReRAM), one of the potential candidates in next-generation memory, has attracted intensive attention owing to its nonvolatility, high writing/reading speed, high density, and low power consumption.\textsuperscript{32-35} ReRAM is promising for the simplicity of device structure, ease of device fabrication and comparability to be fabricated on different types of substrate. An interesting example is the new type ReRAM recently demonstrated on the “paper” substrate, which is constructed by a simple metal-insulator-conductor structure (Ag/TiO$_2$/C) using all-printing techniques (Figure 3a).\textsuperscript{35} This work shows that the ReRAM can be readily fabricated on any flexible substrates and labeled electronics or living objects for multifunctional, wearable-on-skin, and biocompatible applications (Figure 3b). Recently, cellulose-based ReRAM has demonstrated ultra-high flexibility capable being bent down to the radius of 350 µm, which is the smallest value compared to any existing flexible ReRAM.\textsuperscript{35} Due to the simplicity of structure, an ultra-high memory density based on vertical-resistive random access memory is achievable.\textsuperscript{36} Durán Retamal et al. have demonstrate that ultrathin sidewalls of C54-TiSi$_2$ nanoscale electrodes can confine and stabilize the random nature of the resistive switching process by acting as the seeds for conducting nanofilaments growth. As a result, with C54-TiSi$_2$ as horizontal electrodes, a 3D-stacking memory can be achieved (Figure 3c and 3d). Another advantage of the ReRAM is the low power consumption. Very recently, Kang et al. have shown that the nonvolatile memory made by BMO exhibits excellent resistive switching performance and can be operated with ultralow power consumption (i.e., 3.8 and 20 fJ for set and reset process).\textsuperscript{37} The lower consumption power results from the...
conducting nanofilament formation energy, where the nanofilaments are only 10 nm in diameter and are separated by 20–30 nm in spacing, determined by transmission electron microscopy (TEM). Formation of nanofilaments in ReRAM devices has recently been observed by in-situ TEM techniques and conductive atomic force microscopy, revealing the microscopic origin behind resistive switching and offering guidance for the design of novel ionic devices.38,39

Using metal oxide materials as active layers in ReRAM are ideal due to their highly tuneable electric resistance and solid electrolyte characteristics.40–47 Metal oxide material systems, including perovskite-type oxides, ferroelectric oxides, binary transition metal oxides and complex metal oxides, have been demonstrated to be applicable in resistive switching.48–50 However, the surface effect, an intrinsic nature of metal oxide materials, is detrimental to device applications because of the induced electrical instability.51–54 Because the resistive switching mechanism is associated with the formation/rupture of the conductive nanofilaments near the oxide-electrode interface, the switching characteristic could be influenced by the chemisorbed O2 molecules at the surfaces. The evidence is that the interaction between chemisorbed oxygen and oxygen vacancies in oxides dominates the switching features of ZnO-based ReRAM.52 The absorbed oxygen causes an increase of resistance in high resistance state (HRS). Meanwhile, surface effect becomes more and more pronounced during operation due to Joule heating as the voltage is continuously applied. This leads to the fact that the resistive switching performances of oxide memory devices, including switching yield and resistance value fluctuation, are sensitive to the ambiances.

Sealing and packaging are often applied to memory devices to temporarily deal with varied environmental conditions. However, to achieve long-term reliability, it is necessary to modify the material as inert as possible, and thus finding approaches to achieve stable switching is in particular demands. One way to reduce the surface susceptibility is through atomic doping. For example, doping nitrogen into ZnO by employing an atomic layer deposition (ALD) technique has been proposed to improve the stability and reliability of ZnO resistive memory.53 The mechanism is that the doped nitrogen can compensate the native defects and reduce oxygen molecule chemisorption, which suppresses the surface effects on the memory switching behaviours. Consequently, the memory devices exhibit better immunity against ambient conditions. It has been shown that even in mild ambient condition changes, the performance of ZnO resistive memory can be greatly affected. In certain harsh conditions, the degradation of the memory performance becomes worse because some metal oxides are extremely sensitive to corrosive atmospheric exposure surface contamination associated with corrosion attack. For example, ZnO is chemically unstable in acetic conditions.55 The formic acid molecules can weaken the Zn–O bonds, leading to Zn atom dissolution processes, which spread throughout the material until the device failure occurs. Therefore, even though ZnO-based electronic and optoelectronic devices exhibit fascinating performances, severe chemically instability would hinder their practical uses. The surface/interface modification by CF4 plasma treatment improves the resistive switching characteristics of the ZnO thin films.54 This treatment not only prolongs the device endurance, but also stabilizes the switching parameters, including set voltage (Vset), reset voltage (Vreset) and reset current. Moreover, the surface modification with fluorine allows the ZnO ReRAM to withstand severe corrosive conditions (Figure 4a and 4b). Improved ReRAM characteristics, high inertness to surface effect, and high durability in acetic environment are due to surface passivation (saturating the dangling bonds) diminishing the oxygen vacancies) and strong Zn-F bonding (preventing the Zn atoms from dissolution) via the fluorine incorporation. The ability for the devices to operate in various ambiances, including chemically harsh conditions, with long-term durability and reliability will play an important role in the successful emergence of resistive memory based on ZnO.
A new approach to protect the memory from environmental interference is to apply two-dimensional (2D) passivation using atomically thin 2D nanomaterials. 2D materials are the thinnest functional nanomaterials regarded as attractive substitutes to many traditional materials.\(^{55-66}\) Recently, Yang et al. reported that by introducing graphene electrodes as a passivation layer the surface effect in memory can be suppressed via eliminating the detrimental effect from the chemisorbed \(\text{O}_2\) molecules.\(^{44}\) As tested in different atmosphere, ZnO with graphene as passivation layer shows lower variation in switching yield (yield ranging from 66.7% to 75.0%) as compared to that of pristine ZnO (yield ranging from 41.7% to 66.7%) (Figure 5a and 5b). In addition, due to low sheet resistance and high optical transparency of graphene, ZnO memory devices exhibit not only stable resistive switching characteristics but also excellent transparency (less than 2% absorbance by graphene) (Figure 5c).

**Figure 5** Plots for the atmosphere-dependent resistance changes in HRS and LRS of the memory device (a) with and (b) without graphene electrodes. (c) The transmission of ITO/ZnO/ITO/glass (open squares) and ITO/graphene/ZnO/ITO/glass (solid squares) devices within the ITO/graphene/ZnO/ITO transparent ReRAM device. The background can be observed through the device. Copyright 2014, IEEE.

Although the surface effects are mostly unfavourable to memory devices, a well control of the effects can help to promote the performance of memory. Recently, Durán et al. show that the photoelectrical and resistive switching properties of ZnO ReRAM can be tuneable by a treatment of ultraviolet (UV) illumination. Based on the regulation of oxygen photodesorption and readorsorption by UV illumination, the treatment can significantly reduce the variations of resistance in high resistance state, set voltage and reset voltage by 58%, 33%, and 25%, respectively.\(^{67}\) This finding gives physical insight into designing a stable resistive memory device in the future.

### 2.3. Applying the surface effect in gas sensors

Form the photodetectors to memory devices, it has shown that the electronic and optoelectronic properties of metal oxide-based devices can be significantly influenced by engineering the electronic states at surfaces.\(^{68}\) The mechanism is due to the gas adsorption which tunes the electronic band bending at a surface, and apparently, gases in different classes can produce various effects. Based on this mechanism, gas sensors are achievable through a proper design of the metal oxide devices.\(^{69,71}\) There is a strong interest in the development of lightweight gas sensors capable of sensing chemicals in parts-per million (ppm) range with low-power consumption. It has been demonstrated that metal oxide-based sensors are capable of detecting gases, such as \(\text{NO}_2,\)\(^{72}\) \(\text{NH}_3,\)\(^{73}\) \(\text{NH}_4\)\(^{74}\), \(\text{CO},\)\(^{75}\) \(\text{H}_2\)\(^{76}\), \(\text{H}_2\text{O},\)\(^{76}\) \(\text{O}_3,\)\(^{77}\) \(\text{H}_2\text{S},\)\(^{78}\) and \(\text{C}_2\text{H}_5\text{OH},\) with high sensitivity.\(^{79}\) The fundamental mechanism of the gas sensor is to change the conductivity via the electron trapping and releasing on the surface. In principle, as gas molecules are adsorbed on surface, charge transfer occurs which modifies the carrier concentration resulting in a change of conductivity. For example, with \(\text{NO}_2\) or \(\text{O}_3\) adsorption, the molecules tend to capture free electrons on the surface, forming a low-conductivity depletion layer near surfaces and decrease the conductivity of ZnO devices.\(^{80-83}\) On the other hand, reductive gases, such as ethanol, \(\text{H}_2,\) \(\text{CO},\) \(\text{H}_2\text{S},\) react with the charged oxygen molecules on surfaces, and thus free electron concentration is increased due to oxygen desorption, leading to an increase of conductivity.\(^{84-88}\)

Since the gas sensing mechanism relies on the surface effect, the sensitivity of the sensors can be improved by the surface modification which could enhance the surface effect. For example, the sensitivity of ZnO to \(\text{H}_2\) sensing can be improved by Pd clusters decoration on the device surface. The addition of Pd catalytically helps to dissociate \(\text{H}_2\) into atomic hydrogen, increasing the sensitivity of the sensor device. The sensor can detect hydrogen with concentrations down to 10 ppm, whereas there is no response to \(\text{O}_2\). The same concept also works on ZnO NW’s gas sensor, whose \(\text{H}_2\) detection sensitivity can be promoted by Pt coating.\(^{89}\) Electrode selection is another way to improve the gas sensor. For example, using Pt interdigitating electrodes, a metal oxide sensor with gas ethanol sensitivity and fast response at 300°C has been demonstrated.\(^{90}\) Introducing heterojunctions to create hybrid nanomaterials is another strategy to improve the sensitivity. H. et al. has reported that the plasma-polymerized acrylonitrile/ZnO sensor offers significant advantages over conventional ZnO gas sensors.\(^{70}\) The minimum sensitivity can achieve 16.6 ppm, which is decent for gas sensors, especially combined with a low working temperature (Figure 6a). The results show that under UV light illumination oxygen sensing of PP-AN/ZnO NBs can be enhanced significantly because the effects of oxygen desorption/adsorption on the polymer on the electron depletion region of the ZnO is pronounced under UV light (Figure 6b and 6c). The sensing behaviours of the bilayered nanomaterial demonstrated performance in terms of sensitivity and working temperature due to the adsorption nature of the polymer.
2.4. Surface effect in metal oxide transistors

Another fundamental research area of metal oxide are thin film transistors (TFT) and NW field effect transistors (FET). The electrical tunability of metal oxide from insulator to metal, owing to the large divergence in electronegativity between the heavy metal cations and oxygen atoms, has led to the development of high performance transistors with high field-effect mobility (μ), low off current (I_{off}), steep subthreshold swings (SS) slope and large on-off current ratio (I_{on}/I_{off}).

Many studies have shown that oxide TFTs are the best candidates as gate driver and pixel switching devices in the active-matrix of liquid crystal and organic light emitting diode for next generation displays. However, a common problem faced in oxide TFTs is the adverse environmental effect that results from the interaction with ambient molecules and illumination photons on the metal oxide surface. The adsorption/desorption dynamics of molecules and photons onto the exposed channel surface significantly affect performance by reducing μ, increasing I_{on}, lowering SS, reducing I_{on}/I_{off} and shifting threshold voltage (V_{th}) and thus becoming a critical problem for stability (Figure 7a).

The effect of the environmental humidity on metal oxide is of special importance because oxygen and water molecules in the ambient atmosphere are known to induce the degradation of bias-stressed transistors and play an important role in carrier transport. It has been confirmed that adsorbed oxygen on the ZnO surface can capture an electron from the conduction band and that the resulting oxygen species can exist in various forms such as O_{2}^{-}, O^{-}, and O^{2-}, as described by the following chemical reaction: O_{2(gas)} + e^- → O_{2(ads)}^{-98,99}. As a result of charge transfer, a depletion layer is formed beneath the Zn-based oxide surface, leading to reduced carrier concentration that might end up in enhancement mode transistors. The surface effect manifests itself as a continuous increase in V_{th} when the gate bias is kept constant over time (Figure 7b). Assuming an exponential distribution of trap states at room temperature, the V_{th} shift (ΔV_{th}) at infinite stress time is equal to the applied gate bias required to compensate the electric field created by trapped charges before an accumulation layer is formed, yielding a stretched exponential decay for V_{th} with time (ΔV_{th} = \frac{1}{\beta} \exp(-t/\tau)), where r is a characteristic time constant thermally activated, \beta is the dispersion parameter equal to TT_{D}, and V_{0} = V_{th0} - V_{th}. Where V_{th} is the V_{th} at the start of the experiment. The ΔV_{th} is also remarkably more pronounced with the variation of oxygen partial pressure and can be modeled by the Freundlich adsorption model which states that V_{th} at oxygen pressure P can be expressed as ln[V_{th}(P)] = constant + (1/n)ln(P), where n is constant.

Because of the wide band gap of certain metal oxides, transparent transistors can be integrated into displays. However, the surface illumination interaction effect can lead to operation sensitive to visible light irradiation. Figure 7c shows the variation of transfer characteristic under different wavelength illumination. In contrast, regarding the surface interaction with UV illumination as explained in the PD section, there is an advantage in using photo-transistors rather than two-terminal photodetectors due to the photo-response properties that can be modulated by gate bias. When the photo-transistor is in the on-state bias the photocurrent is dominated by the photovoltaic effect and the photo-generation is minimum, because at this gate bias the dark current increases. Whereas, in the off-state, photoconductivity effect...
significant for the transistor, and the photo-generation is maximum, because at this gate bias the carrier injection and thermal generation have the smallest contribution to photo-generation and in turn photo-generated current has the highest contribution just below the SS slope (Figure 7d). However, UV illumination causes significant negative $\Delta V_{th}$ and the recovery upon turn off UV illumination is slow, leading to problems during normal device operation. The $V_g$ instability caused by UV illumination is attributed to positive charge trapping, while the slow recovery involves the recombination of oxygen vacancies, free electrons, and oxygen atoms.\textsuperscript{103} The energy of UV photons would help the oxygen atoms diffuse into an interstitial site. After switching off the UV illumination, the interstitial oxygen atoms require relatively high energies to diffuse back to the lattice site. This is because the diffusing oxygen atoms must overcome the potential barrier due to the surrounding ions. Hence, it takes some time for the system to return to the initial pre-illumination state at room temperature.\textsuperscript{105}

3. Conclusions and Outlook

3.1. Examining the surface effects in electronics

Surface effects are pronounced in nanoscale devices and are proved to have huge impact on the device performance. The effects could cause either a detrimental or beneficial impact based on the application of the devices. Any nanodevice subjected to surface effect must be able to be fabricated and function stably before commercialized. To control the effects, intrinsic capabilities and limiting factors, such as the cause of surface effect and environment interaction, should be well understood in order to engineer the effect. In this review, we have shown that the surface effect can be investigated electrically and optically by different types of measurements, such as field-effect device measurement and UPS. However, challenges to comprehensively control the properties and maintain reliability still remain. After understanding the underlying mechanisms, one can guarantee the required level of device stability and reliability under various external conditions.

3.2. Application of surface effect in devices

For metal oxide optoelectronics, the surface effect contributes to high sensitivity but reduces the response speed. Finding a solution to compensate the trade-off between sensitivity and speed is crucial for pushing the metal oxide optoelectronics into real applications. In this review, we have shown different strategies, including surface modification and geometry design, to improve the response speed and at the same time keep the high sensitivity. In addition, since depleted region is only a few tens of nanometers near the surface, most light is penetrating and absorbed in bulk, wasted by fast recombination. To increase effective absorption, we proposed a resonant model capable of near-surface concentration which is preferred for metal oxide photodetectors. For memory devices, the surface effect is usually detrimental to device applications because of the induced instability. We have examined several environment factors that could affect the performance of the ReRAM, including the gas absorption and corrosive sources. We show that using atomic doping, surface modification and 2D material passivation, it is possible to stabilize the performance of ReRAM from surface effect. Since the gas adsorption is the main cause of surface effect, gas sensing is workable and promising for metal oxide devices. We have shown that by combining nanomaterials in different classes, desired device performance can be achieved and the sensitivity can be improved. The same concepts are applicable in metal oxide transistors. We have shown that by proper treatment of UV light, surface effect can be controlled and the performance of metal oxide can be promoted.


MINIREVIEW

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The surface effect can be either a negative or beneficial effect on nanodevices depending on the environmental conditions and device applications. This review provides an introduction of the surface effects on different types of nanodevices, offering the solutions to response to their benefits and negative effect, and provides outlooks on further applications regarding the surface effect, which is beneficial for designing nano-enabled photodetectors, memories, sensors and transistors via surface engineering.

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